

Notice of References Cited	Application/Control No. 10/767,124	Applicant(s)/Patent Under Reexamination HANSEN, SVEN	
	Examiner Vivian Nelson	Art Unit 2851	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
	A	US-5,739,899	04-1998	Nishi et al.	355/53
	B	US-5,500,736	03-1996	Koitabashi et al.	356/620
	C	US-2005/0117140	06-2005	Mishima, Kazuhiko	355/072
	D	US-2003/0211409	11-2003	Nunes, Christopher C.	430/22
	E	US-			
	F	US-			
	G	US-			
	H	US-			
	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
	O					
	P					
	Q					
	R					
	S					
	T					

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Y. Tanaka, R. Matsuda, K. Shinoyamaa, J. Homma; The Latest Alignment Technology in PCB Step-and-Repeat Projection Exposure System; April 2001; IPC Printed Circuits Expo, 2001; Pgs. S18-2-1 to S18-2-7
	V	
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.